Improving MP2 band gaps with low-scaling approximations to EOM-CCSD

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Despite its reasonable accuracy for ground-state properties of semiconductors and insulators, second-order Møller-Plesset perturbation theory (MP2) significantly underestimates band gaps. Here, we evaluate the band gap predictions of partitioned equation-of-motion MP2 (P-EOM-MP2), which is a second-order approximation to equation-of-motion coupled-cluster theory with single and double excitations. On a test set of elemental and binary semiconductors and insulators, we find that P-EOM-MP2 overestimates band gaps by 0.3 eV on average, which can be compared to the underestimation by 0.6 eV on average exhibited by the G_0W_0 approximation with a PBE reference. We show that P-EOM-MP2, when interpreted as a Green's function-based theory, has a self-energy that includes all first- and secondorder diagrams and a few third-order diagrams. We find that the GW approximation performs better for materials with small gaps and P-EOM-MP2 performs better for materials with large gaps, which we attribute to their superior treatment of screening and exchange, respectively.

by $V_{pq}^{rs} = \langle pq | rs \rangle - \langle pq | sr \rangle$, with

Sec Plesset perturbation theory (MP2) is eatment of dynamical electron correthe si lation akes it especially attractive for large systen dic solids. Although periodic MP2 m reasonably well for the description has be es,^{1–12} its performance is less satisfacof gro on energies and band gaps.^{5,13} For extory fo as applied to thirteen semiconductors ample ited average errors of 0.5% for lattice and in moduli, and 0.23 eV for cohesive enconsta ative band gaps for materials that are ergies know cting, such as silicon and silicon carry performance was attributed to the bide. te-order perturbation theory. Indeed, lack o ^{4–16} and equation-of-motion coupledthe G cluster order semic higher

Here, we study t mation to equationgle and double exe Refs. 23 and 24. Despite making sequential second-order approximations, the method will be seen to be equivalent to the use of a self-energy containing all second-order diagrams and a few third-order diagrams.

Consider the Møller-Plesset partitioning of the many-body Hamiltonian, leading to the Hartree-Fock (HF) orbitals $\phi_p(\mathbf{r})$ with orbital energies ε_p ; as usual, we denote the orbitals occupied in the HF determinant by i, j, k, l, those unoccupied by a, b, c, d, and general orbitals by p, q, r, s. The self-energy evaluated to second-order in perturbation theory is

$$\Sigma_{pq}^{\text{MP2}}(\omega) = \frac{1}{2} \sum_{lcd} \frac{V_{pl}^{cd} V_{cd}^{ql}}{\omega + \varepsilon_l - \varepsilon_c - \varepsilon_d} + \frac{1}{2} \sum_{kld} \frac{V_{pd}^{kl} V_{kl}^{qd}}{\omega + \varepsilon_d - \varepsilon_k - \varepsilon_l},$$
(1)

where the antisymmetrized two-electron integrals are defined

Unlike typical Green's function techniques, the EOM ap-

 $\langle pq|rs \rangle = \int dx_1 dx_2 \phi_p^*(x_1) \phi_q^*(x_2) r_{12}^{-1} \phi_r(x_1) \phi_s(x_2)$

and x is a combined space and spin variable. Unlike the GW

approximation, the MP2 self-energy has exact second-order

proximation to EOM-CCSD, leading to a method originally

referred to as EOM-MBPT(2)²³ or EOM-CCSD(2).²⁵ In this

method, the ground-state CCSD amplitudes are approximated

by their MP2 values, avoiding the expensive iterative solu-

tion of the CCSD amplitude equations. In this work, we con-

sider the additional approximation of partitioning the EOM

An alternative theory can be obtained by a second-order ap-

exchange and is therefore free of self-screening error.

(2)



FIG. 1. Self-energy diagrams included in the MP2 and P-EOM-MP2 Green's function beyond first-order. All diagrams are time-ordered with time increasing from left to right; hole lines point towards decreasing time and particle lines point towards increasing time. All Coulomb interactions (wavy lines) are antisymmetrized, yielding exchange diagrams not explicitly drawn here. The MP2 self-energy includes diagrams (a) and (b) only. The P-EOM-MP2 self-energy includes all four diagrams shown. The GW self-energy includes the non-exchange versions of diagrams (a), (b), (c), and many others.

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proach yields ionization potentials (IPs) and electron affinities (EAs) from separate eigenvalue calculations. In practice, these eigenvalues are found iteratively using the Davidson algorithm. As shown by Nooijen and Snijders,²³ the P-EOM-MP2 IPs can equivalently be obtained from the self-consistent eigenvalues of a matrix with elements $\varepsilon_i \delta_{ij} + \Sigma_{ij}^{\text{EOM}}(\omega)$, where

$$\Sigma_{ij}^{\text{EOM}}(\omega) = \frac{1}{2} \sum_{lcd} \frac{V_{il}^{cd} V_{cd}^{Jl}}{\varepsilon_j + \varepsilon_l - \varepsilon_c - \varepsilon_d} + \frac{1}{2} \sum_{kld} \frac{W_{id}^{kl} V_{kl}^{Jd}}{\omega + \varepsilon_d - \varepsilon_k - \varepsilon_l}$$
(3)

and likewise for the EAs. The above matrix is clearly similar to the MP2 self-energy matrix (1), except for three differences. The first difference is the neglected coupling between the particle and hole spaces. Within the common diagonal approximation to the self-energy, this coupling is irrelevant and we have numerically confirmed that it is a negligible difference in this work. The second difference is the perturbative replacement of $\omega = \varepsilon_j$ in one of the two terms. When this replacement is done in the MP2 self-energy, we find that it makes the results slightly *worse* and is thus not responsible for the improvement to be shown in the P-EOM-MP2 band gaps (vide infra).

The third and most important difference is the presence of the intermediate

$$W_{id}^{kl} = V_{id}^{kl} + P_{-}(kl) \sum_{me} V_{im}^{ke} t_{lm}^{de} + \frac{1}{2} \sum_{ef} V_{id}^{ef} t_{kl}^{ef}$$
(4)

where the antisymmetrization operator is $P_{-}(kl)A_{kl} = A_{kl} - A_{lk}$ and

$$t_{ij}^{ab} = \frac{V_{ab}^{ij}}{\varepsilon_i + \varepsilon_j - \varepsilon_a - \varepsilon_b}.$$
 (5)

Viewed in terms of the similarity-transformed Hamiltonian $\bar{H} = e^{-T}He^{T}$, the first term in Eq. (3) reflects a renormalization of the one-body interactions due to ground-state correlation and the presence of *W* in the second term reflects a renormalization of the two-body interactions, i.e. it is a screened Coulomb interaction. Alternatively, the intermediate *W* can be understood as the inclusion of a few third-order self-energy diagrams, with a perturbative evaluation of the frequency denominator. In Fig. 1, we show the time-ordered self-energy diagrams included in the MP2 and P-EOM-MP2 Green's functions beyond first-order (i.e. beyond Hartree-Fock).

Assuming N_o occupied orbitals and N_v virtual orbitals with $N_v > N_o$, then the more expensive electron affinity EOM-CCSD (EA-EOM-CCSD) has an iterative $O(N_o^2 N_v^4)$ cost due to ground-state CCSD and an iterative $O(N_o^2 N_v^3)$ cost per eigenvalue for excited-state matrix-vector multiplication. The P-EOM-MP2 method reduces the above to a non-iterative $O(N_o^2 N_v^2)$ cost due to ground-state MP2 (ignoring the integral transformation) and an iterative $O(N_o N_v^3)$ cost per eigenvalue due to excited-state matrix-vector multiplication. This significant cost reduction makes P-EOM-MP2 an attractive approach for complex materials. (Strictly speaking, P-EOM-MP2 has a non-iterative $O(N^6)$ step due to the formation of the intermediate (4), but this is typically not the most timeconsuming step. If necessary, the one-time intermediate construction can be avoided but results in an iterative $O(N^5)$ cost.)



FIG. 2. Comparison of calculated band gaps to experimental band gaps (including zero-point renormalization) for the eleven semiconducting and insulating materials indicated. GW approximation results were obtained at the G_0W_0 @PBE level of theory.

We have applied the above two theories to the calculation of the minimum band gaps of eleven simple, three-dimensional semiconductors and insulators. Seven have a diamond/zincblende crystal structure: Si, SiC, GaP, BP, GaN, C, BN; two have a rock-salt crystal structure: MgO and LiF; and two have a face-center cubic crystal structure: Ar and Ne. Calculations were done with periodic boundary conditions using the PySCF software package.^{27,28} All calculations were done without pseudopotentials using the all-electron cc-pVTZ basis set except for Ne and Ar, which used the aug-cc-pVTZ basis set. Calculations using larger basis sets (not shown) suggest that our results are close to the basis set limit, consistent with analogous results obtained with the GW approximation.²⁹ Two-electron integrals were calculated by periodic Gaussian density fitting³⁰ using JKFIT auxiliary basis sets.³¹

For charged excitation energies, finite-size effects are large.^{12,32} Here, we have included one Madelung constant correction to the occupied orbital energies and another to the final IPs. The former correction has no impact in wavefunctionbased theories such as EOM-CCSD, but does have an impact in finite-order perturbation theories (similar to the differing behaviors of ground-state CCSD and MP2); the latter correction is familiar from periodic calculations of charged systems and can be given a many-body interpretation on the basis of the excited-state structure factor.³² We have performed calculations with $N_k = 2^3 - 5^3 k$ -points sampled uniformly in the Brillouin zone. Band gaps were then extrapolated to the thermodynamic limit assuming an $O(N_k^{-1/3})$ finite-size error. Other treatments of finite-size effects are possible, but all are expected to exhibit finite-size errors with the same scaling.

In Fig. 2, we compare the minimum band gaps obtained by MP2, P-EOM-MP2, and the GW approximation to experimental values at 300 K. Because the calculations do not account for vibrational effects, we have adjusted the ex-

Material	a (Å)	Reference		MP2		P-EOM-MP2		G ₀ W ₀ @PBE	
		Expt. $E_{\rm g}$	el-ph	E_{g}	Error	$E_{ m g}$	Error	$E_{ m g}$	Error
Si	5.431	1.24	-0.06	-2.13	-3.43	2.26	0.96	1.08	-0.22
SiC	4.350	2.2	-0.17	-1.21	-3.58	2.66	0.29	2.44	0.07
GaP	5.450	2.27	-0.07	-0.93	-3.27	2.96	0.62	2.33	-0.01
BP	4.538	2.4	-	-2.25	(-4.65)	3.04	(0.64)	2.15	(-0.25)
GaN	4.520	3.30	-0.18	1.68	-1.80	3.70	0.22	3.13	-0.35
С	3.567	5.48	-0.33	1.57	-4.24	5.70	-0.11	5.52	-0.29
BN	3.615	6.2	-0.41	3.00	-3.61	6.15	-0.46	6.41	-0.20
MgO	4.213	7.67	-0.52	7.70	-0.49	8.52	0.33	7.43	-0.76
Ar	5.256	14.2	~ 0	13.80	-0.40	14.38	0.18	13.24	-0.96
LiF	4.035	14.5	-0.59	14.88	-0.21	15.59	0.50	13.27	-1.82
Ne	4.429	21.7	~ 0	21.00	-0.70	21.98	0.28	20.01	-1.69
MSE (eV)					-2.17		+0.28		-0.62
MUE (eV)					2.17		0.40		0.64

TABLE I. Minimum band gap E_g as measured experimentally and as predicted by MP2, P-EOM-MP2 and G_0W_0 @PBE (from Ref. 29). Errors in predicted band gaps are calculated with respect to experimental values with electron-phonon (el-ph) renormalization. All energies are in eV. Mean signed error (MSE) and mean unsigned error (MUE) are given in eV. percentage. Results on BP were excluded from error statistics due to the missing electron-phonon renormalization. Experimental band gaps are from Refs. 33–35, zero-point contributions to electronphonon renormalization are from Refs. 36 and 37, the thermal contribution to electron-phonon renormalization for LiF is from Ref. 38, and G_0W_0 @PBE results are from Refs. 29 and 39.

perimental values according to calculated electron-phonon renormalizations from the literature^{36,37} based on the Allen-Heine-Cardona framework.^{40–42} We only include the zero-point renormalization for all materials except LiF, which has a sizable thermal contribution to the renormalization at 300 K;³⁸ for the other materials, this latter contribution is relatively small. Lattice expansion is already accounted for because our lattice constants are experimental 300 K values. Precise numbers and crystal geometries are given in Tab. I. We note that experimental band gaps and calculated electron-phonon renormalizations vary throughout the literature.

Consistent with Ref. 5, we find that MP2 systematically underestimates the band gap and predicts negative band gaps for Si, GaP, BP, and SiC (our MP2 band gaps are similar to those of Ref. 5, but some differ by as much as 0.5 eV, which we attribute to differences in the treatment of core electrons, basis set effects, finite-size effects). Remarkably, the P-EOM-MP2 band gaps are a significant improvement and show good agreement for all materials. The mean signed error (MSE) is +0.28 eV and the mean unsigned error (MUE) is 0.40 eV. The largest signed error is for Si (+0.96 eV), which has the smallest gap of all materials considered.

In Fig. 2 and Tab. I, we also compare results to those calculated by the G_0W_0 approximation with a PBE reference. For all materials except LiF, we compare to all-electron, fullfrequency calculations by Zhu and Chan,²⁹ which were performed with PySCF using identical treatments of core electrons and identical Gaussian basis sets. The result for LiF is from Ref. 39. Remarkably, the P-EOM-MP2 and GW approximation perform similarly well, despite their underlying physical differences. Roughly speaking, the GW approximation performs better for materials with the smallest gaps while P-EOM-MP2 performs better for those with the largest gaps. The largest errors for the GW approximation are for the largegap insulators, whose band gaps are underestimated by about 1 eV or more, which we attribute to the use of a PBE starting point and the absence of second-order exchange. For the GW approximation, the MSE is -0.62 eV and the MUE is 0.64 eV.

We performed additional calculations to estimate the effect of the various diagrams included in the P-EOM-MP2 selfenergy shown in Fig. 1. The HF band gap is always much too large and the direct second-order diagrams yield a large negative correction, which is largely responsible for the per-



FIG. 3. Convergence and extrapolation to the thermodynamic limit of the MP2 and P-EOM-MP2 band gaps for four example materials. Experimental values are corrected with a zero-point renormalization.

formance exhibited by MP2. Consistent with Ref. 5, we find that the second-order exchange diagrams make a small contribution ($\leq 0.2 \text{ eV}$) for small-gap materials but a larger contribution ($\geq 0.5 \text{ eV}$) for large-gap materials. This can be attributed to the more localized nature of the electronic states in large-gap insulators. The screening diagram in Fig. 1(c) makes a large contribution (1 eV or more) for all materials and is most responsible for the significant improvement of P-EOM-MP2 over MP2. The final diagram in Fig. 1(d), a vertex correction beyond the GW approximation, typically raises the gap by about 0.2 eV.

In Fig. 3, we show the convergence of the band gap towards the thermodynamic limit for four of the materials considered here. As mentioned earlier, the finite-size error is large and must be removed by extrapolation. Interestingly, although MP2 and P-EOM-MP2 give similar band gaps for small kpoint meshes, they exhibit very different convergence to the thermodynamic limit. This difference is largest for materials with small band gaps. We attribute this behavior to our use of Madelung constant corrections in the HF orbital energies. These corrections cause the HF gap to converge to the thermodynamic limit from above, such that the systems with smaller k-point meshes are more weakly correlated and the importance of third-order diagrams in the self-energy is diminished. On approach to the thermodynamic limit, the system becomes more strongly correlated and the results of the two methods deviate.

In conclusion, we have shown that the P-EOM-MP2 approach, a second-order approximation to EOM-CCSD, yields solid-state band gaps that are a significant improvement over those predicted by MP2. The success of P-EOM-MP2 contradicts the conventional wisdom that infinite-order screening is necessary for quantitative accuracy in band gap prediction. Rather, P-EOM-MP2 represents an affordable balance of loworder screening and exchange, yielding semiquantitative accuracy for materials with a wide range of band gaps. By starting from Hartree-Fock theory and including antisymmetrization in all interaction vertices, the method is completely ab initio and free of self-interaction and self-screening errors. We note that P-EOM-MP2 is very similar to CC243 and we therefore expect similar performance from the latter, which also includes some amount of orbital relaxation. Although P-EOM-MP2 has been found to perform well for three-dimensional materials, it will be interesting to apply it to low-dimensional semiconductors, where screening is more complicated.

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